

## Accepted Manuscript

Fabrication of Si and Ge nanoarrays through graphoepitaxial directed hardmask block copolymer self-assembly

Anushka S. Gangnaik, Tandra Ghoshal, Yordan M. Georgiev, Michael A. Morris, Justin D. Holmes

PII: S0021-9797(18)30666-0  
DOI: <https://doi.org/10.1016/j.jcis.2018.06.018>  
Reference: YJCIS 23709

To appear in: *Journal of Colloid and Interface Science*

Received Date: 7 February 2018  
Revised Date: 5 June 2018  
Accepted Date: 6 June 2018

Please cite this article as: A.S. Gangnaik, T. Ghoshal, Y.M. Georgiev, M.A. Morris, J.D. Holmes, Fabrication of Si and Ge nanoarrays through graphoepitaxial directed hardmask block copolymer self-assembly, *Journal of Colloid and Interface Science* (2018), doi: <https://doi.org/10.1016/j.jcis.2018.06.018>

This is a PDF file of an unedited manuscript that has been accepted for publication. As a service to our customers we are providing this early version of the manuscript. The manuscript will undergo copyediting, typesetting, and review of the resulting proof before it is published in its final form. Please note that during the production process errors may be discovered which could affect the content, and all legal disclaimers that apply to the journal pertain.



**Fabrication of Si and Ge nanoarrays through graphoepitaxial directed hardmask block copolymer self-assembly**

Anushka S. Gangnaik,<sup>a,b\*</sup> Tandra Ghoshal,<sup>a,b</sup> Yordan M. Georgiev,<sup>a,b</sup> Michael A. Morris,<sup>a,b</sup>  
Justin D. Holmes<sup>a,b</sup>

<sup>a,b</sup>School of Chemistry and Tyndall National Institute, University College Cork, Cork, Ireland

[\*] Corresponding Author:

Tandra Ghoshal

Tel: + 353 21 490 2911

Fax: +353 21 427 4097

E-mail: g\_tandra@yahoo.co.in

Download English Version:

<https://daneshyari.com/en/article/6989047>

Download Persian Version:

<https://daneshyari.com/article/6989047>

[Daneshyari.com](https://daneshyari.com)